



Software solutions for  
optimizing micro & nano  
fabrication processes



## First Announcement

# BEAMeeting 2020 at the MNE, Leuven, Belgium Technical Workshop & Discussion

**MNE2020**  
MNE CONFERENCE LEUVEN, BELGIUM

14TH - 18TH SEPTEMBER 2020 | THE LEADING CONFERENCE ON NANO AND MICRO ENGINEERING

Date: Monday, 14 September, 2020  
Place: Leuven, Belgium  
Time: Monday, 09:00 until 17:30  
Contact: Haiyan Cozzio-Fu  
E-Mail: [marketing@genisys-gmbh.com](mailto:marketing@genisys-gmbh.com)

Our BEAMeetings are focussed on E-Beam lithography, data-preparation, PEC, process correction, and lithography simulation. The meeting is a technical exchange platform for BEAMER users and those who are interested in BEAMER and other GenISys software. Please bring inputs on any topic of your preference, User presentations on applications, solutions for specific issues and needs are very welcome. Please let us know if you would like to give a short presentation. The final agenda will be based on your inputs. Do not hesitate to communicate requests and suggestions to make the BEAMeeting most interesting and valuable for the BEAMER community.

The BEAMeeting is free of charge – lunch is included. Further information regarding venue, program etc. will be mailed when available.

The BEAMeeting will be held at the MNE, Leuven, Belgium.

For our planning, please register with an email to: Haiyan Cozzio-Fu - [marketing@genisys-gmbh.com](mailto:marketing@genisys-gmbh.com).

We are looking forward to seeing you in Leuven in September 2020!

The GenISys Team